

ABSTRACT

**SPUTTERING TARGET, SINTERED BODY, CONDUCTIVE FILM FORMED
BY USING THEM, ORGANIC EL DEVICE, AND SUBSTRATE USED
FOR THE ORGANIC EL DEVICE**

The present invention relates to a metal oxide thin film comprising one, two or more types of oxides selected from zinc oxide and tin oxide, and at least one or more types of lanthanide metal oxides. The specific resistance is from $10E+4 \text{ } \Omega\text{cm}$ to $10E+8 \text{ } \Omega\text{cm}$.

Figure 2